EVG receives “Grand Achievement Award” for nanoimprint technology

30 years of dedication and research in the field of nanoimprint lithography honored at the 24th International Conference on Nanoimprint and Nanoprint Technology (NNT).

Dana Point, CA, USA, October 14, 2025—EV Group (EVG), a leading provider of innovative process solutions and expertise serving leading-edge and future semiconductor designs and chip integration schemes, today announced that it has received the “30 Years Nanoimprint Grand Achievement Award”.

The award was presented at the 24th International Conference on Nanoimprint and Nanoprint Technology (NNT), being held this week in Dana Point, California, in celebration of a major milestone: the 30-year anniversary of the invention of nanoimprint lithography (NIL) by Prof. Stephen Chou of Princeton University in 1995.

Professor Fabian Pease of Stanford University, a pioneer in nanotechnology whose work has significantly shaped the field, presented the award to EVG for “transformative contributions to nanoimprint through pioneering, development, and commercialization of high-volume manufacturing tools enabling worldwide industrial deployment.”

EVG has a strong showing at NNT this year. In addition to receiving the award and exhibiting its industry-leading NIL solutions, which have been widely adopted to address the volume manufacturing needs for a variety of commercial applications, EVG is contributing to the high-caliber conference program with two presentations:

- **Thomas Glinsner** (Corporate Technology Director) is giving a plenary talk titled *“From Experimental to Essential – NIL’s Evolution in Industry”*, highlighting NIL’s journey from research to industrial application.
- **Johanna Rimböck** (Technology Development) is presenting in a technical session: *“From coffee rings to slopes: Solid content effects in inkjet coating for NIL”*.

For more information on EVG’s NIL solutions, please visit: https://www.evgroup.com/products/nanoimprint-lithography

About EV Group (EVG)

EV Group (EVG) provides innovative process solutions and expertise for implementing cutting-edge semiconductor designs and 3D integration of microchips. The company’s mission and vision — to be first in new technologies and to support the most advanced applications in micro- and nanotechnology — enable customers to successfully market their new product ideas. EVG’s products, designed for high-volume production, include wafer bonding, lithography, thin-wafer processing, and metrology systems. These solutions drive further advancements in semiconductor frontend scaling, 3D integration, advanced packaging, and other electronics and photonics applications. More information at **www.EVGroup.com**.

Contact

Clemens Schütte
Director, Marketing and Communications
EV Group
Tel: +43 7712 5311 0
E-mail: Marketing@EVGroup.com